APPLICATION DATA SHEET

JC20 Rec'd PCT/PTO 2 1 SEP 2009

(1) Applicant Information

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(3) Application Information

Title:

A METHOD FOR MANUFACTURING A MEMBRANE IN

A (111) SURFACE OF A (100) SILICON WAFER

Total No. of Drawing Sheets:

Suggested Figure for Publication:

1A-1D

Docket Number:

6900-26

Type of Application:

PCT National Phase

(4) Representative Information

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(5) Domestic Priority Information

This application is a §371 National Phase of PCT/NL2004/000197, filed March 22, 2004

(6) Foreign Priority Information

Foreign priority:

NL 1022995, filed March 21, 2003

(7) Assignee Information

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